

1-17-03
L. Spruwell

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:

Robert H. Havemann

Docket No.: TI-27506

Serial No.: 10/001,472

Examiner: Wojciechowicz, E.

Filed: 11/01/01

Art Unit: 2815

FOR: INTEGRATED CIRCUIT HAVING A DOPED POROUS DIELECTRIC AND METHOD OF
MANUFACTURING THE SAMEREQUEST FOR EXTENSION OF TIME

Assistant Commissioner of Patents

Washington, DC 20231

Dear Sir:

Pursuant to 37 CFR 1.136(a), Applicant(s) respectfully petitions the Commissioner for an extension of the shortened statutory period for response in the above-identified Application.

FAX RECEIVED

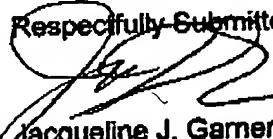
The fee for this extension is indicated below:

One Month (\$110)
 Two Months (\$400)
 Three Months (\$920)
 Four Months (\$1,440)

DEC 13 2002

TECHNOLOGY CENTER 2800

Please charge the fee to deposit account no. 20-0668. Any further necessary extension of time is hereby requested. Charge any and all fees to deposit account no. 20-0668. An original and two copies of this sheet are enclosed.

Respectfully Submitted,

 Jacqueline J. Garner
 Reg. No. 36,144

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